

JRC/6/322  
JC474 U.S. Pro  
10063094  
03/19/02

PATENT NUMBER and  
ISSUE DATE

U.S. UTILITY Patent Application

APPL NUM 10063094	FILING DATE 03/19/2002	CLASS 427	SUBCLASS 218.1	GAU 1762	EXAMINER <i>Meeks</i>
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\*\*APPLICANTS: Yang Barry; Iacovangelo Charles; Browall Kenneth; Gasworth Steven; Morrison William; Johnson James;

\*\*CONTINUING DATA VERIFIED:

THIS APPLICATION IS A DIV OF 09/681,820 06/11/2001

\*\* FOREIGN APPLICATIONS VERIFIED:

PG-PUB	DO NOT PUBLISH <input type="checkbox"/>	RESCIND <input type="checkbox"/>	
Foreign priority claimed, 35 USC 119 conditions met		<input type="checkbox"/> yes <input type="checkbox"/> no <input type="checkbox"/> yes <input type="checkbox"/> no	ATTORNEY DOCKET NO
Verified and Acknowledged Examiner's initials		RD-27190-2	
TITLE : Apparatus and method for large area chemical vapor deposition using multiple expanding thermal plasma generators			

U.S.DEP'T. OF COMM./PAT. & TM-PTO-436L(Rev. 12-94)

NOTICE OF ALLOWANCE MAILED		Assistant Examiner	CLAIMS ALLOWED	
			Total Claims	Print Claim for O.G
ISSUE FEE		DRAWING		
Amount Due	Date Paid	Sheets Drwg.	Figs. Drwg.	Print Fig.
TERMINAL DISCLAIMER		Primary Examiner		
		PREPARED FOR ISSUE		
		Application Examiner		
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